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Docket No.: 101361-0043

10/11/02  
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Dated: October 3, 2002

Signature:

(Reza Mollaaghababa)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Robert P. Dolan, et al.

Application No.: 09/884,451

Group Art Unit: 2823

Filed: June 19, 2001

Examiner: J. Maldonado

For: SIMOX USING CONTROLLED WATER  
VAPOR FOR OXYGEN IMPLANTS

**INFORMATION DISCLOSURE STATEMENT (IDS)**

Commissioner for Patents  
Washington, DC 20231

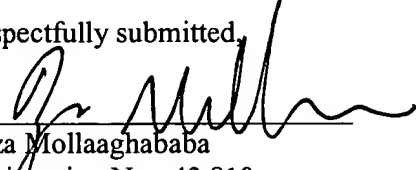
Dear Sir:

Applicants wish to make of record in the above-referenced continuation application activities that occurred more than one year prior to its original filing date, that is, more than a year prior to June 24, 1999 (the date that parent application Ser. No. 09/399,633 was filed). Briefly, these activities were experimental uses of an ion implantation machine to test the methods of the present invention. The experimental use arose pursuant to an agreement between IBIS Technology Corporation (IBIS), the assignee of the present invention and its customer, International Business Machines Corporation (IBM). During the period from October, 1996 through June, 1998, IBM tested an ion implantation system known as IBIS 1000 that had been manufactured by IBIS and provided IBIS with feedback. The tests included the practice of at least some of the methods claimed in the present application.

An affidavit from Angelo V. Alioto of IBIS is submitted herewith further describing the tests and confidentiality obligations that were in place at the time.

Dated: October 3, 2002

Respectfully submitted,

By   
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